Material Supply Innovations Safe, sustainable and cost efficient solutions.

Andreas Weisheit 2011





The Linde Group

Innovative gas supply solutions

Innovative PECVD chamber clean

Our References

The World's Leading Gas and Engineering Company 11.2bn Euro sales. Present in more than 100 countries.

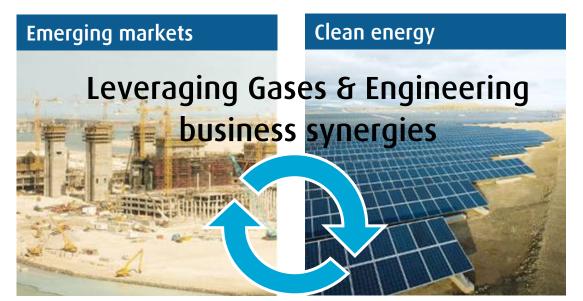








GROWTH





Linde Offering to the Solar Industry



Turnkey scope

On-site Gas Generation (N_2, H_2, F_2, O_2)

Bulk Gas Supply Systems (N_2, H_2, O_2, Ar, He)

Bulk Specialty Gas Systems (NH₃, SiH₄, NF₃)

Specialty Gas Cabinets (NH₃, PH₃, CH₄, TMB, B₂H₆)

Valve Distribution Boxes, Valve Manifold Boxes

Piping to the tools

Gas Leak Detection, Gas Monitoring

Compressed Dry Air

Value Added Services

Application know-how & Engineering

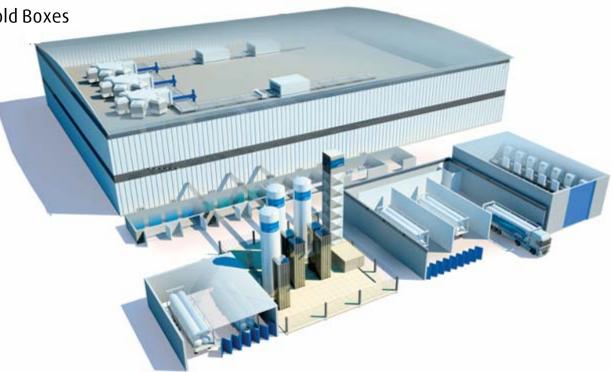
Process Optimisation

Own Research & Development

Engineering & Hook-up Planning

Permitting

Total Gas & Chemical Management





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Global Linde Silane Footprint



HOW do we deliver Silane?

WHERE are

LINDE Sources?

- Linde's supply chains provide maximum security of supply & flexibility for our customers.
- Dedicated trailer fleet and buffer stocks in place across the continents.

USA (> 1000MT Source)

China, Taiwan

Europe

USA

EUROPE (>300 MT Source)

Europe

China

Taiwan

KOREA (>1500 MT Source)

China
Taiwan
Europe

WHY use Global Silane?

- Linde have access to silane sources in 3 continents with >2000 MT contracts in place.
- Independent locations provide mitigation of currency and political risk.

Lowest Cost of Ownership by on-site dopant blending





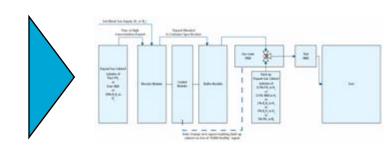
Dopant gases are typically delivered as 0.5...5% mixture in H_2 .

Dopant gases are hydrides from group III (e.g. TMB) or group V (e.g. PH3) elements that can alter the electrical properties of a semiconductor layer and make it p(+) or n(-) conductive.

HOW do we deliver it?

Dynamic Dopant
Blending Systems
use pure hydrides
and H2 available
from the tankfarm
to make the mix





WHY use DDBS?

✓ Safety

Less cylinder handling steps

 \checkmark

Cost Reduction Reduced cost of ownership

✓

CO₂ Footprint

Eliminates cylinder shipping

On-site Hydrogen Supply

The experience of the world's leading Hydrogen engineers.



WHICH
Technology for
Hydrogen?

Multiple on-site generation technologies: Electrolysis, Steam Methane Reforming, Methanol cracking.

- High reliability and lowest cost of ownership.
- Quick installation and ease of maintenance.
- Conventional and reliable catalyst systems, proven reactor & PSA technology.

HOW do we deliver it?

Capacities from <50 to >1000 NM³/hr



Proven technology =



The Leading on-site Hydrogen supply

WHY use LINDE?

Linde Hydrochem – manufacturers of over 200 Steam Methane Reformers. Linde Installed record of Electrolysers





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WHAT is Fluorine?

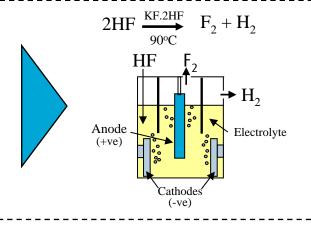
Fluorine is the active ingredient in all silicon chamber cleaning.

Fluorine gas (F_2) is a faster and environmentally friendly replacement for Greenhouse Gases like NF₃ used to clean waste silicon from CVD process chambers

HOW do we deliver it?

Generation-F® On-site Fluorine Generation Systems





WHY use Fluorine? **Productivity**

Faster chamber cleaning improves PECVD tool throughput, typically between 4 and 12%

Cost Reduction Direct material cost saving of >15%

Sustainability

F₂ has **Zero Global Warming Potential**, eliminates risk of Green House Gas emissions and lowers overall CO₂ footprint

Linde Delivers: F₂ Cleaning in European Photovoltaics



Experience in Electronics Applications

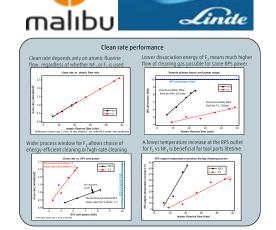






Successful Development Program in PV





Implementation in manufacturing

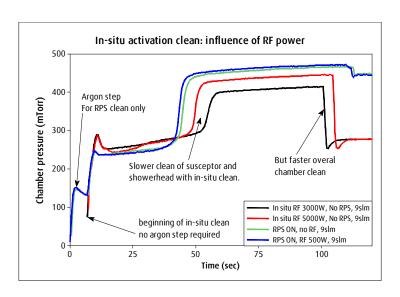




Linde Delivers: continuous application improvement

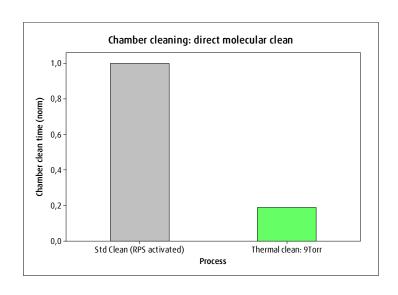


In-situ activated clean



- High dissociation by RF plasma.
- Chamber clean shorter than with RPS activation.
 - → Higher uptime
 - → lower cleaning costs
 - → Lower CAPEX & maintenance

Direct molecular clean



- F2 is reactive with silicon at temperature <200°C.
- No plasma activation required (no RPS).
- 80% clean time reduction achieved.
- No ion bombardment, ,gentle' clean.
 - → Lowest Cost of Ownership

Safe supply by on-site generation



Never experienced an F₂ leak or fire, in > 10 years.

Fluorine reactivity is well understood and managed safely at low pressures, low velocities and with proprietary system designs.

Complete surface passivation ensures system durability.

Linde F_2 Systems operate at < 1.5 bar.

- On-site systems operated in > 12 electronics customer facilities since 2001 with no F₂ incidents.
- Linde's Intellectual Property Patents, trade secrets and know-how ensure long term safe, reliable, high purity operation



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In Electronics, in all major sectors, Linde's strategy is closely linked to the most dynamic growth leaders.



Semiconductor

First choice for the top semiconductor manufacturers.

Linde is currently executing major gas supply projects for each of the top 3 semiconductor manufacturers with a combined investment value of >Eur200m

- > # in logic (USA)
- # in memory (KOR)
- ➤ #1 in Foundry (TW)

Photovoltaic

- First choice for thin film customers the world over:
 - 0erlikon (7/11)
 - AMAT (8/11)
 - ULVAC (2/4)
 - Apollo (4/4)
- ➤ First choice for the global #1module maker in c-Si (China)
- ➤ First choice as a technical partner:
 - Thin film JDPs
 - c-Si JDPs
- ➤ First choice for emerging regions
 - India (>75%)

LED

First choice in Asia

- Taiwan customers are #1 and #2 HB LED makers.
- China currently executing gas supply projects for 6 major new fabs
- China Justexecuted the firstGrade 7.0 domesticAmmonia plant.
- ➤ Europe & USA long-term contracts with #1 in each region.

TFT-LCD

First choice in China

➤ Currently
executing the first
2 Gen 8 TFT fabs in
China with a
combined
investment value
of >Eur45m

First choice for F2





Thank you for your attention

Linde Electronics.

The power behind tomorrow's technologies